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Dr. Charles B. Duke, Xerox Webster Research Center, 800 Phillips Road, Bldg. 0114-38D, Webster, NY 14580, USA
Telefax: +1-716-265-5080; Electronic mail: warthman.wbst128@xerox.com

Associate Editor

Dr. L.J. Brillson, Xerox Webster Research Center, 800 Phillips Road, Bldg. 0114-38D, Webster, NY 14580, USA
Telefax: +1-716-265-5080; Electronic mail: warthman.wbst128@xerox.com

Regional Editors

Dr. Richard M. Lambert
Department of Chemistry
University of Cambridge
Lensfield Road
Cambridge CB2 1EW
UK
Fax: +44-1223-336362
E-mail: rml1@cus.cam.ac.uk

Professor Yoshitada Murata
Division of Natural Science
University of Electro-Communications
1-5-1 Chofugaoka, Chofu
Tokyo 152
Japan
Fax: +81-424-84-7403

Professor Klaus Wandelt
Institut für Physikalische und Theoretische Chemie der Universität Bonn
Wegelerstraße 12
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A special feature of the journal is the periodic inclusion of proceedings of symposia and conferences on aspects relevant to the study of the physics and chemistry of interfaces.

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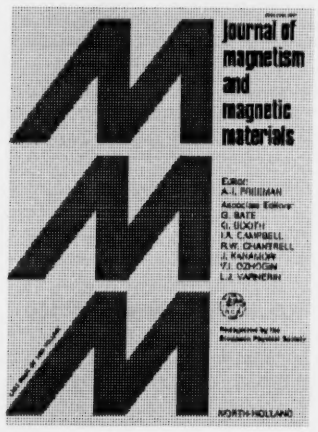

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